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05 Mar 2003

SUBJECT: Authorization for Release of Technical Information, Control Number: AFRL-PR-ED-VG-2003-055

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American Chemical Society Conference

(Statement A)

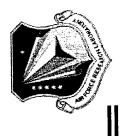
(New Orleans, LA, 23-27 Mar 2003) (Deadline: 24 Feb 2003 - PAST DUE)



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Living next door to a Fluorine Chemist

POSS is not just a sphere



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Anatomy of a Polyhedral Oligomeric Silsesquioxane (POSS) Molecule



Nonreactive organic (R) groups for solubilization and compatibilization.

and a R-R distance of 1.5 nm. Nanoscopic in size with an Si-Si distance of 0.5 nm

functional groups suitable for polymerization or graffing. - May possess one or more

(organic-inorganic) framework. Thermally and chemically robust hybrid

Precise three-dimensional structure for molecular level reinforcement of polymer segments and coils.

interaction at the nano-level (Edwards AFRL/PRSM ---> POSS monomers) The maximization of property enhancements in polymers results from





Physical properties of fluorinated Materials

Palyethelyne	0.92-1	105–140	2,3	0.33	83	Susceptible to hot hydrocarbons	404 0.008 264	104-6×104	1.51	Yes
Polyteiru- Nunruethykiie	2.2-2.3	342 (first) 327 (second)	2.0	₩O.0	18	Excellent. No known solvent	505 0.000002 339	101-01	1.35	No
Property	Density	Melting Temperature, °C	Dielectria Constant (1 kHz)	Dynamic Coefficient of Friction	Surface Energy, dynes/g	Resistance to Solvents and Chemicals	Thermal Stability' T _{1/2} ,°C k ₃₅₀ %/min E _{rets} kJ/mol	Melt Viscosity, ² Poise	Refractive Index	Chain Branching Propensity

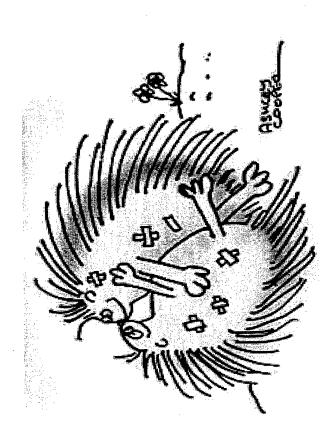
 T_{LG} is the temperature at which 50% of the polymer is lost after thirty minutes heating in vacuum; k_{150} is the rate of volatilization, i.e., weight loss, at $350^{\circ}C$; E_{act} is the activation energy of thermal degradation.

 2 Melt creep viscosity for PTFE at $380^{\circ}\mathrm{C},$ as specified in US Patent 3,819,594 (pub. 625.74).

- PTFE has one of the lowest surface energies among the organic polymers
- 2. PTFE is the most chemically resistant organic polymer
- 3. PTFE is one of the most thermally stable among organic polymers
- PTFE's melting point and specific gravity are more than double PF's



How do Porcupines Mate

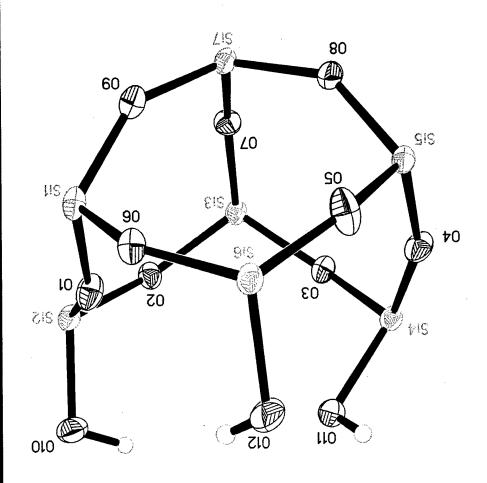


Very carefully!

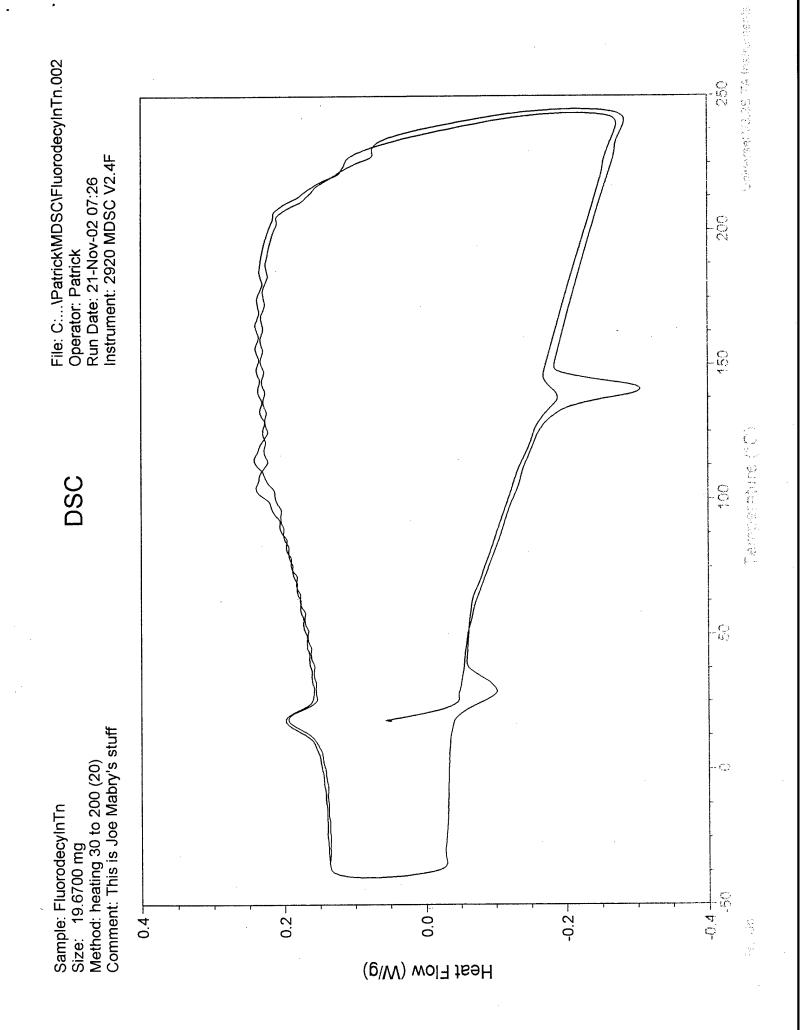




Crystal Structure of Perfluorinated POSS







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kerri_new

HEDM/PRS EQUINOX 55

Sample Scans 500 Raman Laser Wavenumber 9394

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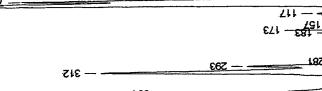
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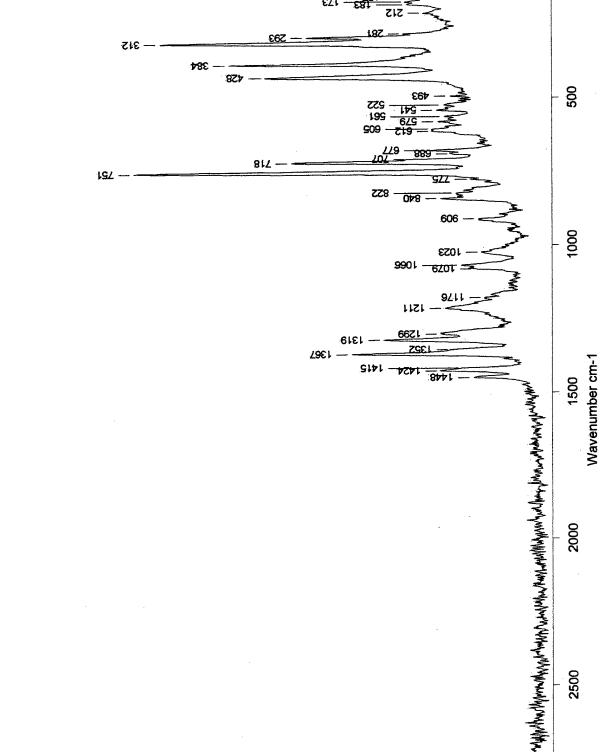
8262

900.0

- S623

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†00'0



Sample: RLB-IV-26 fluorooctyl8T8 Sample Source: white powder Laser Power: 600

0

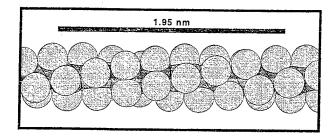


FIGURE 30.19. Polytetrafluorethylene (Form IV).

Polytetrafluoroethylene [-(CF₂)-] Form I (above 30 °C). Space group (hexagonal packing of helical chains of variable twist). Hexagonal approximation a=0.567 nm (35 °C) to 0.574 nm (218 °C). c=0.1300 nm per CF₂ group[†]. Cell volume=0.0362-0.0371 nm³ per CF₂ group. Density =2290-2240 kg/m³. Diffuse pattern with sharp hk0 reflections (hexagonal).

TABLE 30.11. Polytetrafluoroethylene [-(CF₂)-] Form II (below 19 °C). Observed hk0 reflections.^a

d-value (nm)	$2\theta \text{ (deg)}$ (λ =0.1542 nm)	Relative intensity	
0.4866	18.23	vvs	
0.2823	31.69	vs	
0.2447	36.73	s	
0.2414	37.24	m	
0.1850	49.26	m	
0.1828	49.88	m	
0.1627	56.58	m	

^aSpace group (approximate) P1 [C_1^{\dagger}] (Complex structure with a regular helix of 2.1598 CF₂ units per turn). Orthogonal approximation; a=0.9649 nm; b=0.5648; and c=0.1300 nm per CF₂ group[†]. Cell volume=0.03542 nm³ per CF₂ group. Density=2340 kg/m³. (From Ref. 9.)

Polytetrafluoroethylene [-(CF₂)-] Form III (high pressure) Space group Pnam [D_{2h}^{16}]. a=0.75 nm; b=0.56 nm; and c=0.26 nm † . Cell volume=0.1092 nm 3 . Density=3040 kg/m 3 . Peaks attributed to a monoclinic phase are also observed. (From Ref. 10.)

TABLE 30.12. Polytetrafluoroethylene [-(CF_2)-] Form IV (19–30 °C).^a

hkl	d value (nm)	2θ (deg) (λ=0.1542 nm)	Relative intensity
100	0.4902	18.10	vvs
110	0.2830	31.61	s
200	0.2451	36.67	s
210	0.1853	49.18	m
300	0.1634	56.30	m
220	0.1415	66.02	m
310	0.1359	69.09	m
107	0.2422	37.12	vs
108	0.2183	41.37	vs
117	0.1985	45.70	w
118	0.1847	49.34	w

^aSpace group (presumed) P3₁ or P3₂ [C_3^2 or C_3^3]; Rotational disorder of helical chains. $Z=15(\text{CF}_2)$. a=0.566 nm and c=1.95 nm[†]. Cell volume=0.0541 nm³. Density =2302 kg/m³. (From Refs. 8, 9, 11 and 12.)

30.8 POLY(P-PHENYLENE TEREPHTHALAMIDE) (PTTA) [—(C=O)—(C $_6$ H $_4$)—(C=O)—NH—($_6$ H $_4$) —(NH)—]

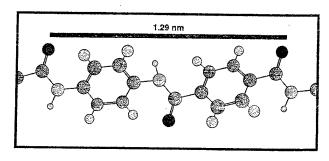


FIGURE 30.20. Poly(*p*-phenylene terephthalamide).

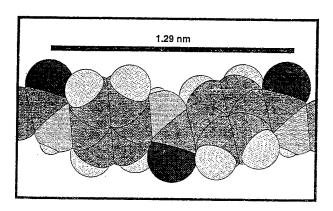


FIGURE 30.21. Poly (p-phenylene terephthalamide).

Linear Fluorocarbon Analogs



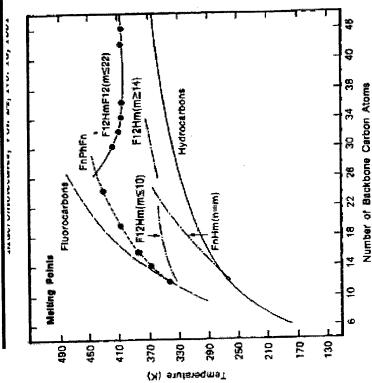


Figure 2. Comparison of the melting points of the FnPhFn tribiocks with those of the n-alkanes, perfluoro-n-alkanes, and previously studied diblock and tribiock materials.

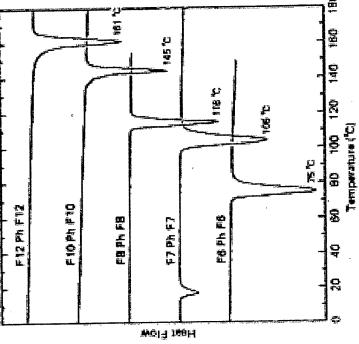


Figure 1. Differential scanning calorimetry thermograms of the PhPhP triblocks. Temperatures refer to peak positions.



Tweig et. al.; Macromolecules 1991,24, 3901-3905

Conclusions

- Fluorosubstituted POSS has unusual melting behavior-evidence of polymorphs
- "coupled" arm motions although Raman spectroscopy does not show Melting point much higher than the arm melting-consistent with strong evidence of a lattice mode
- Frustrated Crystallization due to steric effects?
- Interactions with Karl Christe will solve the puzzle



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- POSS Group

